

REPORT

LM336-2.5 – Low Dose Rate Testing @ 36 rad h⁻¹ ESTEC - Contract No. 22051/08/NL/PA

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5 List of Abbreviations

AIT	Austrian Institute of Technology
CMRR	Common Mode Rejection Ratio
CNS	Centre National d'Études Spatiales
CTB	Component Technological Board
CTR	Current Transfer Ratio
DIL	Dual In Line
DEL	Dosimetry Eichlabor (Dosimetry Laboratory)
DUT	Device Under Test
EEE	Electrical Electronic Electromechanical
ELDRS	Enhanced Low Dose Rate Sensitivity
ESA	European Space Agency
ESCC	European Space Component Coordination
ESTEC	European Space Research and Technology Centre
HDR	High Dose Rate
HDR-S	High Dose Rate – exposure of the switching experiment
HZL	Hot Cell Laboratory
IC	Integrated Circuit
LDR	Low Dose Rate
LDR-C	Low Dose Rate – Continuous exposure
LDR-S	Low Dose Rate – exposure of the switching experiment
LET	Linear Energy Transfer
NES	Nuclear Engineering Seibersdorf GmbH
OTA	Operational Transconductance Amplifier
PCB	Printed Circuit Board
PSRR	Power Supply Rejection Ratio
RD	Reference Document
RWG	Radiation Working Group
SCADUS	Smart Control and Development Universal Software
SOW	Statement Of Work
SR	Slew Rate
TID	Total Ionizing Dose
TRR	Test Readiness Review
TN	Technical Note
VEE	Visual Engineering Environment
WO	Work Order
WP	Work Package

6 Scope and Objectives

This report journalizes low dose rate measurements conducted with the LM336-2.5 microcircuit at a dose rate of $36 \text{ rad}_{(Si)} \text{ h}^{-1}$. Results obtained from these measurements serve as a reference for an experiment that is investigating the accelerated switching test method (see [BOC04], [BOC05], [DUS08], and [BOC09]). The low dose rate degradation is measured for an extensive set of parameters.

This report serves as measurement protocol and a detailed reference data collection. In detail this report includes:

- General overview of the measurements
- Information on DUT properties (e.g. manufacturer, date code, lot ID)
- Enumeration of the DUTs (naming conventions) during the experiments
- Exposure plan
- Dose levels received by each DUT during the exposure
- Measured low dose rate data for each unit and each characterized parameter

7 General Overview of the Measurements

The low dose rate exposure is using a constant dose rate Co-60 photon field with a dose rate of approximately $10 \text{ mrad}_{(Si)} \text{ s}^{-1}$. The exposure is only interrupted for characterisation of the DUTs, which are performed on average every three to four weeks. In terms of total dose this means that a characterisation is done approximately every $20 \text{ krad}_{(Si)}$. 115 days of continuous exposure are needed to reach the specified total dose level of $100 \text{ krad}_{(Si)}$.

All units are mounted on one PCB that is presented in Figure 1. It is noted that this PCB is used also for other experiments that are carried out in parallel. Biased units are positioned in the centre of the board. They are arranged in columns of five units, in each column the biased units of one device type is mounted. To the left and to the right the unbiased units are mounted on antistatic foam that is wrapped in aluminium. This ensures that all pins are grounded. The pin to ground resistance is typical less than 4Ω . A RadFET dosimeter is used to monitor the dose received by the DUTs.

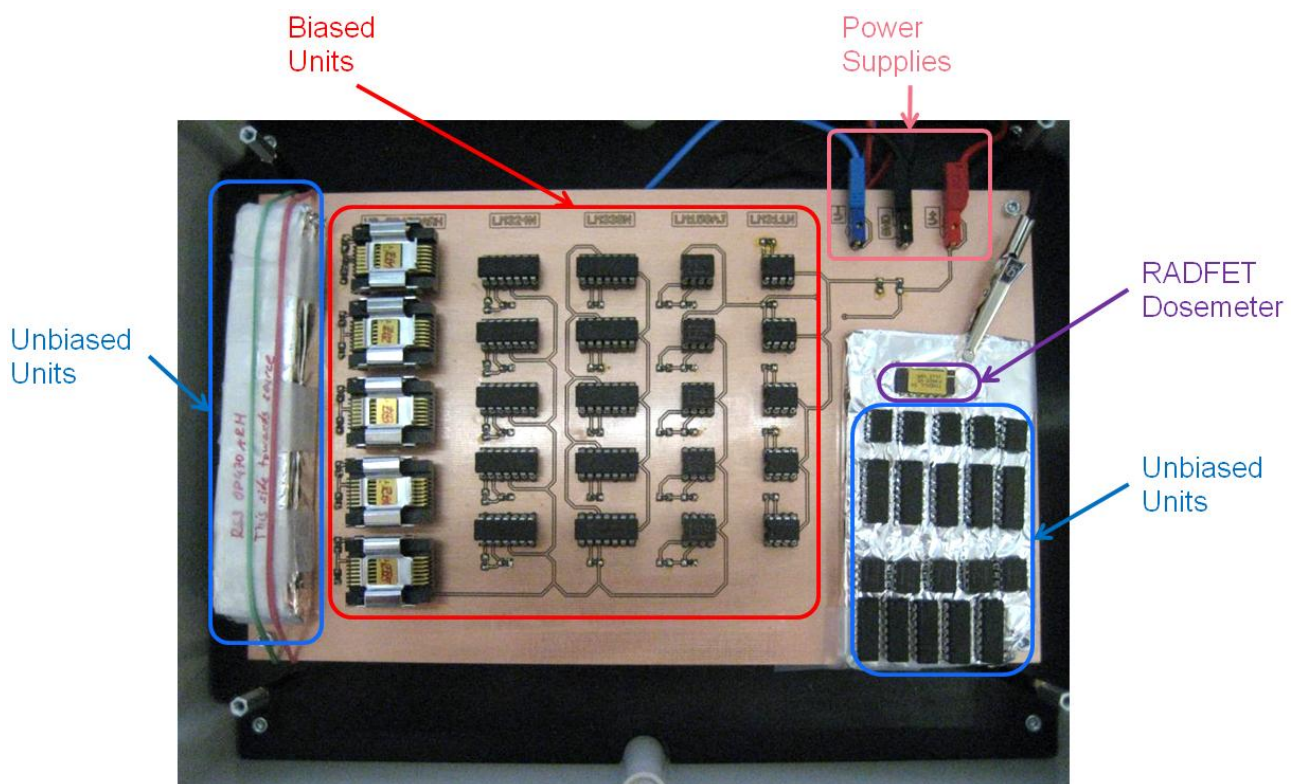


Figure 1: Printed circuit board housing all the biased and unbiased units used for the reference measurements during exposure.

The Co-60 source used for the exposure has an activity of 16.41 Ci (607 GBq); the source is mounted in a portable housing that is a gamma ray radiography camera, i.e. in a Gammamat TK-30. The required dose rate of $10 \text{ mrad}_{(Si)} \text{ s}^{-1}$ is available at a distance of approximately 70 cm from the point source.

The source is kept in a shielding made from depleted Uranium encircled by a stainless steel housing. The source can be moved in and out from the shielding via a locating channel. The source is turned off when it is completely retracted and the Uranium shutter is closed. For exposure the shutter is opened and the source is moved within the locating channel into a defined position. The result is a defined radiation field with the shape of a cone. The field will be adjusted in such a way, that it is sufficiently large to irradiate three irradiation boards in parallel. A picture of the setting is shown in Figure 2.

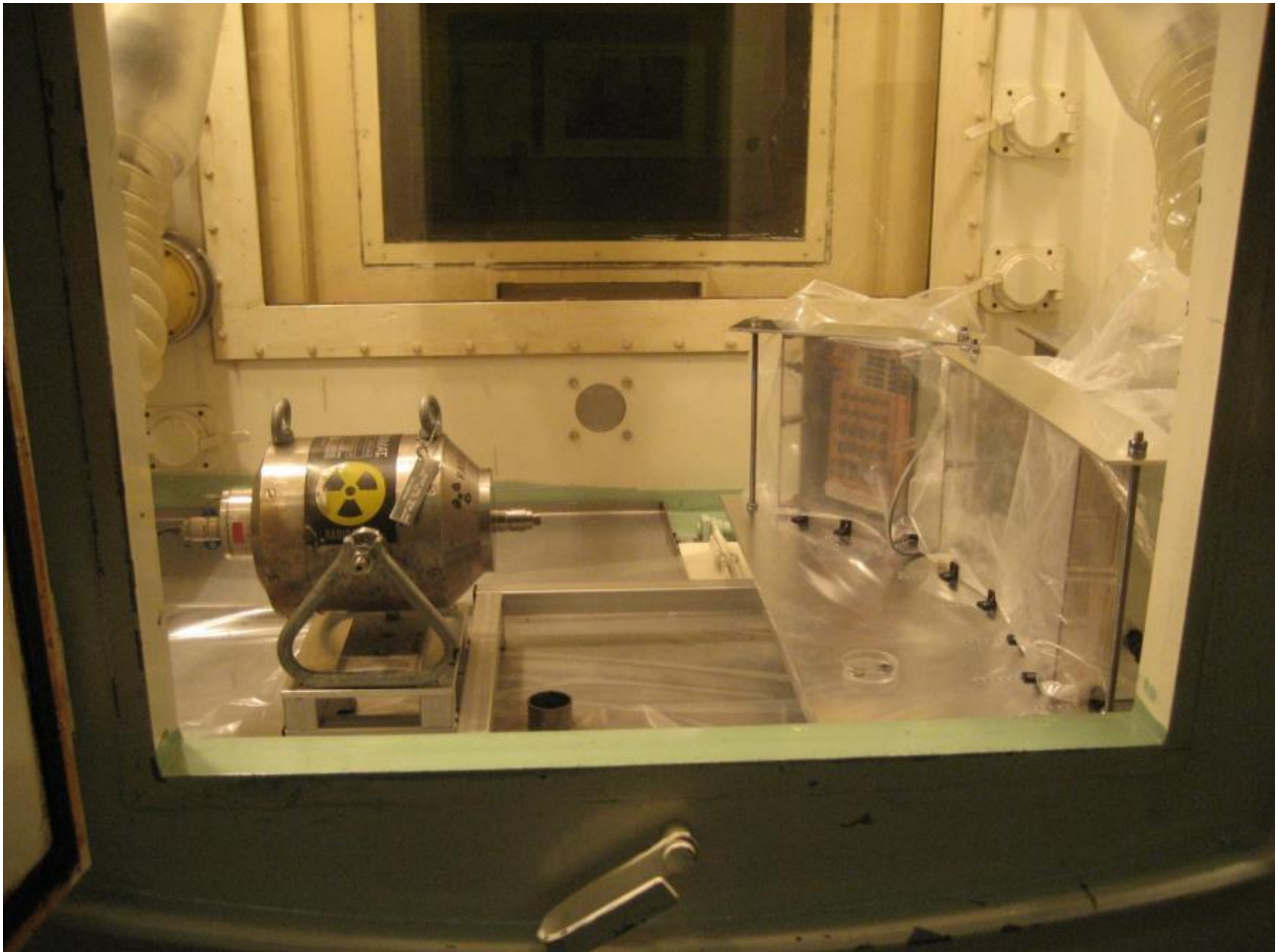


Figure 2: Low dose rate facility; on the left side the radiography camera is positioned, on the right side up to three boxes can be mounted that house one PCB each. The PCB used for the experiments reported here is mounted in the leftmost box.

8 DUT properties and Sample Enumeration

Ten units of the LM336-2.5 microcircuit are used for the low dose rate exposure; five units are exposed in biased condition and another five units are exposed in unbiased condition (see Section 9). Some basic device properties are presented in Table 1.

Table 1: Manufacturer, data code, and lot of the units used for reference exposure

Device Type	Manufacturer	D/C	LOT
LM336-2.5	National Semiconductor	C0818AB	CZAT2047E019

The units used for the low dose rate exposures are divided in two groups five units each. One group is exposed in biased condition, the other group in unbiased condition. All the five samples of either group are treated identically. Enumeration of the samples is shown in Table 2.

Table 2: Enumeration of the samples

Exposure Series / Dose Rate	Biasing Condition	Enumeration
Low Dose Rate / 36 rad _(Si) h ⁻¹	biased	BRef1, BRef2, BRef3, BRef4, BRef5
	unbiased	URef1, URef2, URef3, URef4, URef5

9 Biasing Conditions

Tests are conducted in biased and unbiased configuration. In the unbiased configuration all terminals of the microcircuits are held at ground potential. When using biased condition the microcircuits are driven under typical operational conditions. The test circuitry used for the experiments is described in the following.

9.1 Unbiased Configuration

The pins of the microcircuit are held at ground potential during the exposure to the ionizing radiation. Hereby they are mounted in antistatic foam that is enwrapped in aluminium foil. The foil itself is connected to ground potential. The pin to ground resistance is typical well below a few Ohms.

9.2 Biased Configuration

The biased configuration of the reference diode is based on a configuration of a typical use case as shunt diode. The current is limited to 1 mA (for details see section 12).

10 Exposure Plan for Low Dose Rate Testing and Cumulative Dose Levels

The low dose rate applied to all units during the low dose rate exposure is 10 mrad_(Si) s⁻¹. The exposures are performed in steps of approximately 20 krad_(Si). In between two of such steps the DUTs are removed from the facility and transferred to the lab. An extensive parametric device characterisation is performed to investigate the low dose rate radiation response of the DUTs. After characterisation all the units are remounted in the irradiation facility and the exposure is continued.

Table 3 presents a time table of all exposure steps and the length of the breaks, during which parametric device characterization is done. The cumulative dose to which the DUTs were exposed (at the end of each exposure setup) is presented in the rightmost column.

Table 3: Time table of the low dose rate exposure steps and cumulative dose levels to which the DUTs have been exposed.

Action #	Date	Exposure Stop	Exposure Resume	Duration of Interruption	Cumulative Dose Level
1	4 th May 2011	-----	10:00	-----	0.00 krad _(Si)
2	1 st June 2011	11:45	16:00	4:15	21.68 krad _(Si)
3	28 th June 2011	10:00	13:50	3:50	42.35 krad _(Si)
4	20 th July 2011	10:15	16:00	5:45	59.22 krad _(Si)
5	18 th August 2011	10:10	15:30	5:20	81.44 krad _(Si)
6	31 st August 2011	10:30	-----	-----	91.32 krad _(Si)

11 Measured Low Dose Rate Data



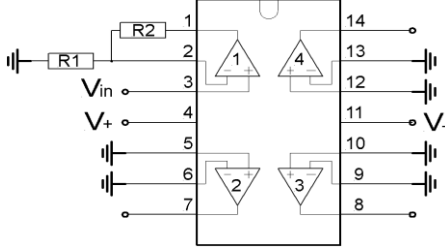
The parametric device degradation of all units is measured with a parameter analyzer. Measurement Data are presented as parameter value vs. dose (in units of $\text{krad}_{(Si)}$) for all parameters presented in Table 4. Data are presented as tabled values as well as in plots. For each device type and biasing condition five units are irradiated under identical conditions. The tabled data present the results of all five units as well as average values and the standard deviations. In the plots only the average values are presented. Uncertainty bars are calculated as the standard deviation.

The reference data obtained for LM336-2.5 microcircuit is presented in Annex A: Reference data obtained with the LM336-2.5 microcircuit.

Table 4: Parametes measured

Electric Parameter used for the characterization of the low dose rate degradation	Symbol
Output Voltage	V_{OUT}

12 Test Plan – Summary

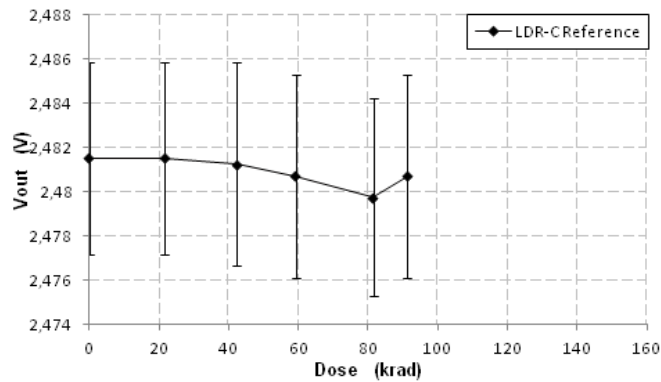
				Total Dose Test Report For: LM336-2.5	
Family: Voltage Reference Package: SOIC		Lot Code: CZAT2047E019 Manufacturing Date Code: C0818AB		Manufacturer: National Semiconductor Contact Person: Kirby Kruckmeyer Address: 2900 Semiconductor Drive, Santa Clara, California, USA	
Test Facility Name: Nuclear Engineering Seibersdorf GesmbH Address: Forschungszentrum Seibersdorf, Seibersdorf, A-2444		Irradiation Test Plan: No.: AIT-9 Iss.: 1 Rev.: 0			
Irradiation Conditions: Biased (In-Situ) & Unbiased Electrical Measurement: Parameters Tested: V_{OUT} Temp: 26 °C		Biased Configuration: Supply Voltages: V_i : +5V Resistor: R: 2.5k Ω Unbiased Configuration: All terminals grounded; pin to ground resistance typically < 4 Ω		Schematic of Test Circuitry: 	
Facilities: Hot Cell Laboratory of the Nuclear Engineering Seibersdorf GesmbH Source: gamma Energy: Co-60 (1.17 MeV, 1.33MeV) Dose Rate: 8.94 mrad _(SI) s ⁻¹ Absorber Material: PMMA Thickness: 3mm Duration: 129.5 d					
Anneal Test: No					
Irradiation Sequence					
Step No.	Description	Begin	End	Exposure Time	
1	Long term exposure Exposure is interrupted several times for ~2 hours for characterization of the electrical parameters. Electrical characterization is done at dose levels of: 21.7, 42.4, 59.2, 81.4, and 91.3 krad _(SI)	4 th May 2011	31 st August 2011	119 d	
Irradiation Test Facility: Responsible Name: Michael Wind Telephone: +43 (0) 50550 - 4310			Electrical Test: Responsible Name: Michael Wind Telephone: +43 (0) 50550 - 4310		

13 References

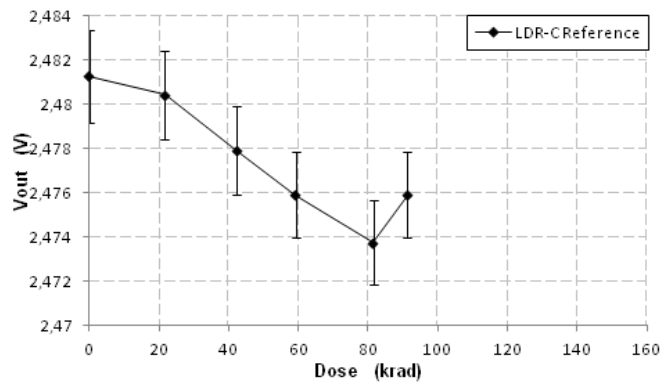
- BOC04 J. Boch, F. Saigné, R.D. Schrimpf, D.M. Fleetwood, S. Ducret, L. Dusseau, J.P., David, J. Fesquet, J. Gasiot, R. Ecoffet, Effect of Switching From High to Low Dose Rate on Linear Bipolar Technology Radiation response, IEEE-TNS, vol.51(5), p.2896, October 2004
- BOC05 J. Boch, F. Saigné, R.D. Schrimpf, J.-R. Vaillé, L. Dusseau, S. Ducret, M. Bernard, E. Lorfèvre, and C. Chatry, Estimation of Low-Dose-Rate Degradation on Bipolar Linear Integrated Circuits Using Switching Experiments, IEEE-TNS, vol. 52 (6), p. 2616, December 2005
- BOC09 J. Boch, Y. Gonzalez Velo, F. Saigné, N. J-H. Roche, R.D. Schrimpf, J.-R. Vaillé, L. Dusseau, C. Chatry, E. Lorfèvre, R. Ecoffet, A.D. Touboul, The use of a Dose- Rate Switching Technique to Characterize Bipolar Devices, submitted to IEEE-TNS, accepted for NSREC, 2009
- DUS08 L. Dusseau, M. Bernard, J. Boch, Y. Gonzalez velo, N. Roche, E. Lorfèvre, F. Bezerra, P. Calvel, R. Marec, F. Saigné, Review and Analysis of the Radiation - Induced Degradation Observed for the Input Bias Current of Linear Integrated Circuits, IEEE-TNS, vol. 55 (6), p.3174, December 2008
- NAT09 National Semiconductor Corp., LM136-2.5/ LM236-2.5/ LM336-2.5 Reference Diode, datasheet, 2009

Annex A: Reference data obtained with the LM336-2.5 microcircuit

Raw Data	Device Type: LM336-2.5	Parameter: Vout (V)	Biasing Condition: Biased				
LDR-C Reference	Dose (krad)	0.00	21.68	42.34	59.22	81.43	91.31
	BRef1	2.48	2.48	2.48	2.48	2.48	2.48
	BRef2	2.48	2.48	2.48	2.48	2.48	2.48
	BRef3	2.47	2.47	2.47	2.47	2.47	2.47
	BRef4	2.47	2.47	2.47	2.47	2.47	2.47
	BRef5	2.48	2.48	2.48	2.48	2.47	2.48
	Mean	2.48	2.48	2.48	2.48	2.47	2.48
	StdDev	4.37E-03	4.37E-03	4.61E-03	4.61E-03	4.49E-03	4.61E-03



Raw Data	Device Type: LM336-2.5	Parameter: Vout (V)	Biasing Condition: Unbiased				
LDR-C Reference	Dose (krad)	0.00	21.68	42.34	59.22	81.43	91.31
	URef1	2.47	2.47	2.47	2.47	2.47	2.47
	URef2	2.48	2.48	2.47	2.47	2.47	2.47
	URef3	2.48	2.48	2.48	2.47	2.47	2.47
	URef4	2.47	2.47	2.47	2.47	2.47	2.47
	URef5	2.48	2.47	2.47	2.47	2.47	2.47
	Mean	2.48	2.48	2.47	2.47	2.47	2.47
	StdDev	2.10E-03	1.97E-03	1.99E-03	1.93E-03	1.91E-03	1.93E-03



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